PROCEEDINGS OF SPIE

AOPC 2025: Optical Design, Testing, and Manufacturing

Lingbao Kong

Editor

24–27 June 2025 Beijing, China

Sponsored and Organized by Chinese Society for Optical Engineering (CSOE) (China)

Technical Cosponsor SPIE

Published by SPIE

Volume 13960

The papers in this volume were part of the technical conference cited on the cover and title page. Papers were selected and subject to review by the editors and conference program committee. Some conference presentations may not be available for publication. Additional papers and presentation recordings may be available online in the SPIE Digital Library at SPIEDigitalLibrary.org.

The papers reflect the work and thoughts of the authors and are published herein as submitted. The publisher is not responsible for the validity of the information or for any outcomes resulting from reliance thereon.

Please use the following format to cite material from these proceedings: Author(s), "Title of Paper," in AOPC 2025: Optical Design, Testing, and Manufacturing, edited by Lingbao Kong, Proc. of SPIE 13960, Seven-digit Article CID Number (DD/MM/YYYY); (DOI URL).

ISSN: 0277-786X

ISSN: 1996-756X (electronic)

ISBN: 9781510698642

ISBN: 9781510698659 (electronic)

Published by

SPIE

P.O. Box 10, Bellingham, Washington 98227-0010 USA Telephone +1 360 676 3290 (Pacific Time)

SPIE.ora

Copyright © 2025 Society of Photo-Optical Instrumentation Engineers (SPIE).

Copying of material in this book for internal or personal use, or for the internal or personal use of specific clients, beyond the fair use provisions granted by the U.S. Copyright Law is authorized by SPIE subject to payment of fees. To obtain permission to use and share articles in this volume, visit Copyright Clearance Center at copyright.com. Other copying for republication, resale, advertising or promotion, or any form of systematic or multiple reproduction of any material in this book is prohibited except with permission in writing from the publisher.

Printed in the United States of America by Curran Associates, Inc., under license from SPIE.

Publication of record for individual papers is online in the SPIE Digital Library.



Paper Numbering: A unique citation identifier (CID) number is assigned to each article in the Proceedings of SPIE at the time of publication. Utilization of CIDs allows articles to be fully citable as soon as they are published online, and connects the same identifier to all online and print versions of the publication. SPIE uses a seven-digit CID article numbering system structured as follows:

- The first five digits correspond to the SPIE volume number.
- The last two digits indicate publication order within the volume using a Base 36 numbering system employing both numerals and letters. These two-number sets start with 00, 01, 02, 03, 04, 05, 06, 07, 08, 09, 0A, 0B ... 0Z, followed by 10-1Z, 20-2Z, etc. The CID Number appears on each page of the manuscript.

Contents

vii Conference Committee

OPTICAL DESIGN AND MANUFACTURING

13960 02	Research on visual response performance of color parameters in aircraft cockpit display interface under complex light environment [13960-1]
13960 03	Modeling of CH ₄ /H ₂ /Ar plasma in dry etching of CdZnTe microlens array [13960-2]
13960 04	Design and development of a hybrid confocal-interferometric probe system with commor path [13960-3]
13960 05	Design of DPP EUV exposure detection device [13960-4]
13960 06	Optical performance prediction and reverse design of phosphor LEDs using deep neural networks optimized by genetic algorithms [13960-5]
13960 07	Research and development of point-focusing x-ray curved crystal monochromator based on microfocus x-ray source [13960-6]
13960 08	Analysis of imaging quality and parameters for flexible variable-focus cylindrical lens under dynamic external force drive [13960-7]
13960 09	Design and analysis of propagation phase polarization multiplexed dielectric metalenses [13960-8]
13960 OA	Prediction of scattering caused by fabrication errors in micro-field EUVL projection optics [13960-9]
13960 OB	Curved glass thickness measurement method based on line spectral confocal principle [13960-11]
13960 OC	Design of a reflective mirror structure based on an improved multiobjective animated oat optimization algorithm [13960-13]
13960 OD	Study on the surface mechanical properties and polishing process of magnesium aluminate spinel [13960-14]
13960 OE	DMD diffraction propagation model and frequency-domain energy optimization under incoherent illumination [13960-16]
13960 OF	A study of trajectory planning for in situ measurements of hemispherical shell resonator geometric error [13960-18]

13960 OG	Structure design and verification of lightweight rectangular folding mirror [13960-19]
13960 OH	Atomic level processing mechanism and analysis of CaF $_2$ crystal nanoindentation by molecular dynamics simulation [13960-22]
13960 OI	Structural and dielectric modification of aluminum nanohole arrays for surface plasmon resonance [13960-23]
13960 OJ	Modeling of the removal function for oblique-axis polishing of single-crystal silicon with a robotic arm [13960-25]
13960 OK	Design method of an ultra-thin two-dimensional hybrid waveguide near-eye display based on forward-ray-tracing and global optimization algorithm [13960-26]
13960 OL	Thermal focus shift in high-power laser image transfer system [13960-27]
13960 OM	Development of mid-wave infrared antireflection coating based on Ge ₁₀ Se ₅₀ As ₄₀ chalcogenide glass [13960-28]
13960 ON	The impact of internal random fluctuating vacuum channels on the emission performance of photocathode $[13960\text{-}31]$
13960 00	A highly stable synthetic wavelength phase demodulation algorithm for multiwavelength interferometric ranging [13960-34]
13960 OP	Comparative study of forward- and backward-scattered light for subsurface-defect detection in nonfluorescent materials [13960-35]
13960 OQ	Optical system design and active alignment methods for wide-field astronomical telescopes [13960-36]
13960 OR	Research on the influence of support and bonding methods of primary mirror with offset hole on its surface wavefront aberration [13960-38]
13960 OS	TDI line-scan dark-field scattering detection of wafer defects based on hierarchical integration diffusion model [13960-39]
13960 OT	Ultraprecision fabrication of the Wolter-I mandrel based on the SPDT and wheel polishing technologies $[13960\text{-}42]$
13960 OU	Single beam 3DoF ultraprecision interferometer based on wave-front interference image [13960-43]
13960 OV	Bending analysis of size-dependent functionally graded nanobeams [13960-44]
13960 OW	Precise toroidal mirror metrology using computer-generated hologram in long trace profiler [13960-45]
13960 OX	Neural network for off-axis four-mirror optical system alianment [13960-46]

13960 OY	A fiber-based dispersive displacement sensor for three-degree-of-freedom measurement [13960-47]
13960 OZ	Automated detection method for aspheric surface [13960-48]
13960 10	Hybrid assembly and alignment method for large-aperture space mirrors [13960-49]
13960 12	Research on wafer image enhancement based on deep learning [13960-51]
13960 13	Design of myopia control lenses based on diffusion optics and progressive addition technologies [13960-52]
13960 14	Design of a high-resolution microscopic system for wear measurement based on aspheric Schwarzschild objective [13960-53]
13960 15	DeepSeek-assisted elliptical flow-line method for LED freeform surface uniform illumination design [13960-54]
13960 16	Energy transfer model and optimization strategies for Fourier ptychographic microscopy [13960-55]
13960 17	Research on modular splicing technology of detector [13960-67]
13960 18	Design, analysis, and testing of a high-performance UVI [13960-77]
13960 19	Vertical axis remote sensing payload installation and adjustment technology [13960-79]
13960 1A	Research on precision tool setting technology based on in situ optical imaging [13960-82]
	OPTOELECTRONICS TESTING AND MEASUREMENT
13960 1B	Compensation correction for point-like source saturation in calorimeter readout detection [13960-10]
13960 1C	Design and simulation analysis of an optomechanical probe for precision voltage measurement [13960-12]
13960 1E	High-precision microring resonator temperature sensing technology based on widely tunable lasers [13960-17]
13960 1F	Theoretical study on error analysis and compensation of dual vortex retarder Mueller matrix ellipsometry [13960-20]
13960 1G	High-precision polarization angle measurement via polarization camera and statistical analysis [13960-21]

13960 1H	Characteristics of wavelength standard system based on two-photon transition in $^{87}\mbox{Rb}$ atoms $[13960\text{-}24]$
13960 11	Research on grayscale gain testing technology for EBCMOS digitalized low-light level devices [13960-29]
13960 1J	Microlens array position errors analysis and evaluation of Hartmann wavefront sensor calibration systems [13960-30]
13960 1K	Testing technology for field-of-view defects in EBCMOS devices [13960-32]